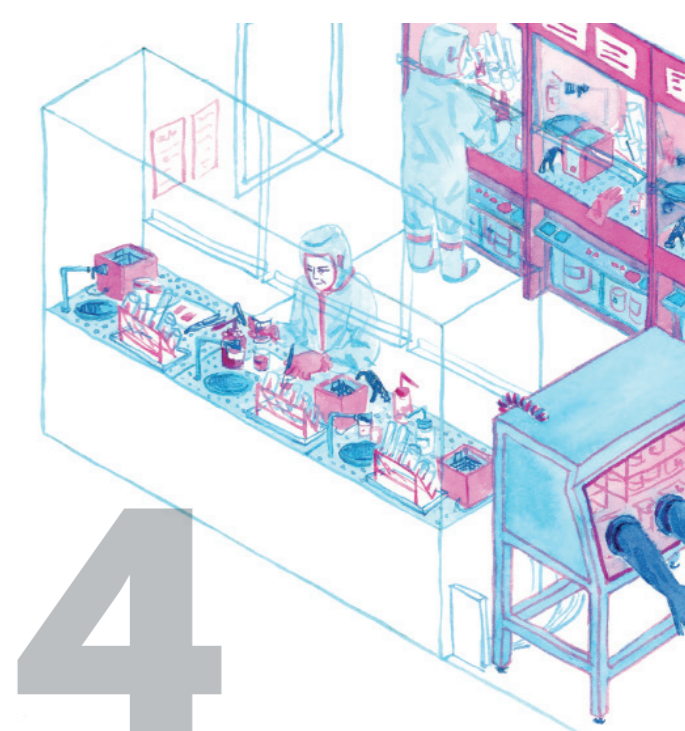
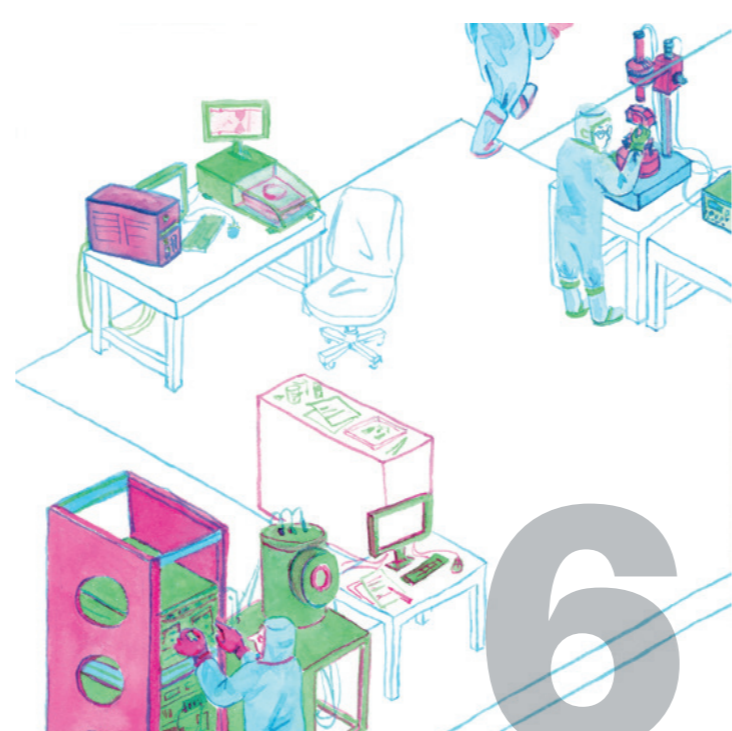
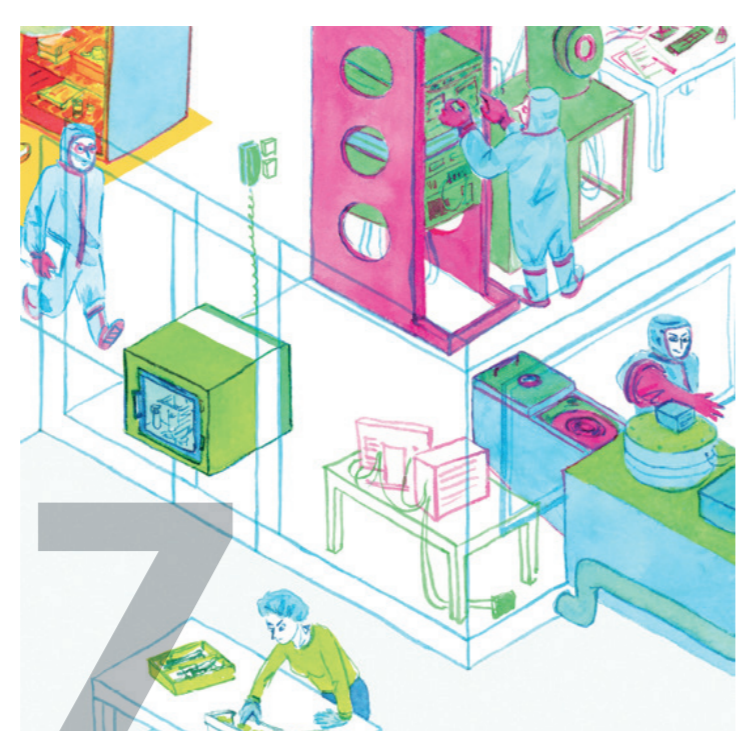
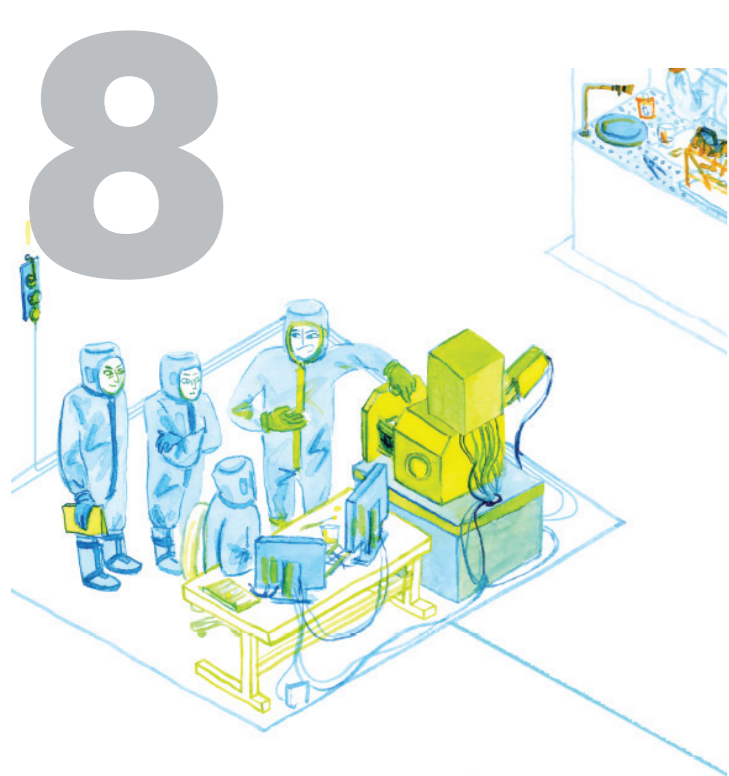
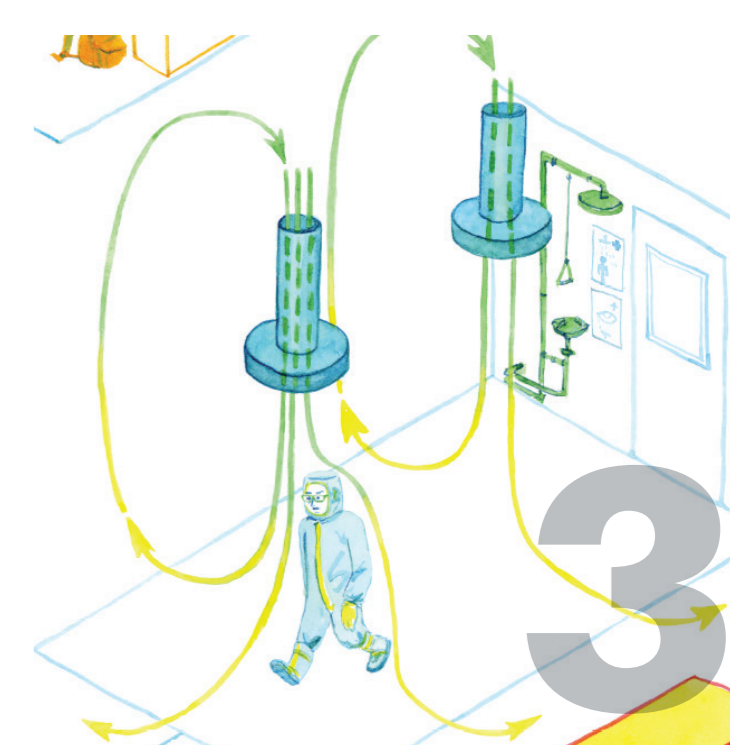
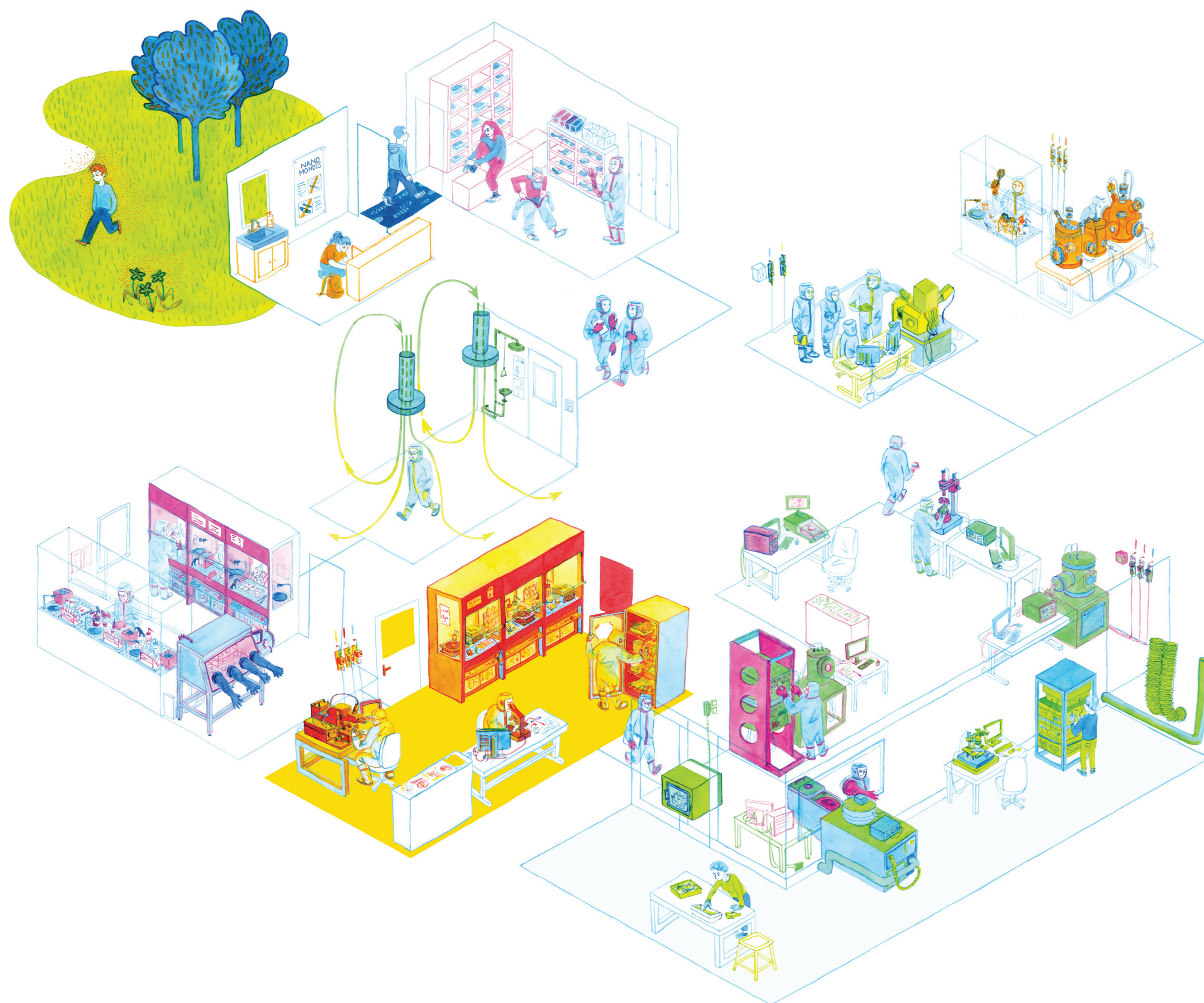


The clean room

The clean room is a space where the size and number of particles is controlled. It is then possible to fabricate structures smaller than these particles.



1 Cloakroom

3 Air is filtered and recycled. It is directed toward the floor and the outside so the particles cannot enter.

5 Yellow zone: UV light is filtered which gives a yellow hue to the light. Photolithography is carried out in this room.

7 Area where many instruments can be found for characterization or fabrication purposes (etching, evaporation...)

2 Airlock: sticky carpet and a bench to separate the cleanroom from the outside.

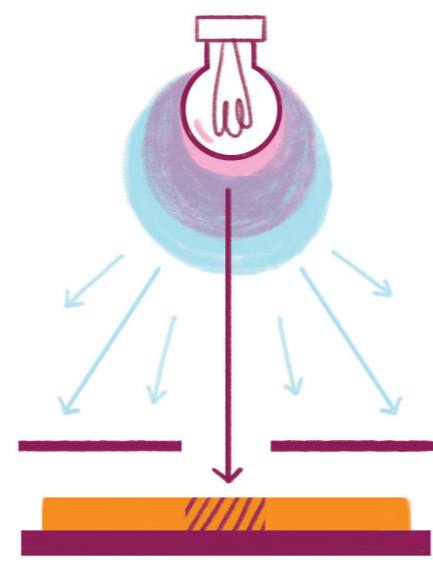
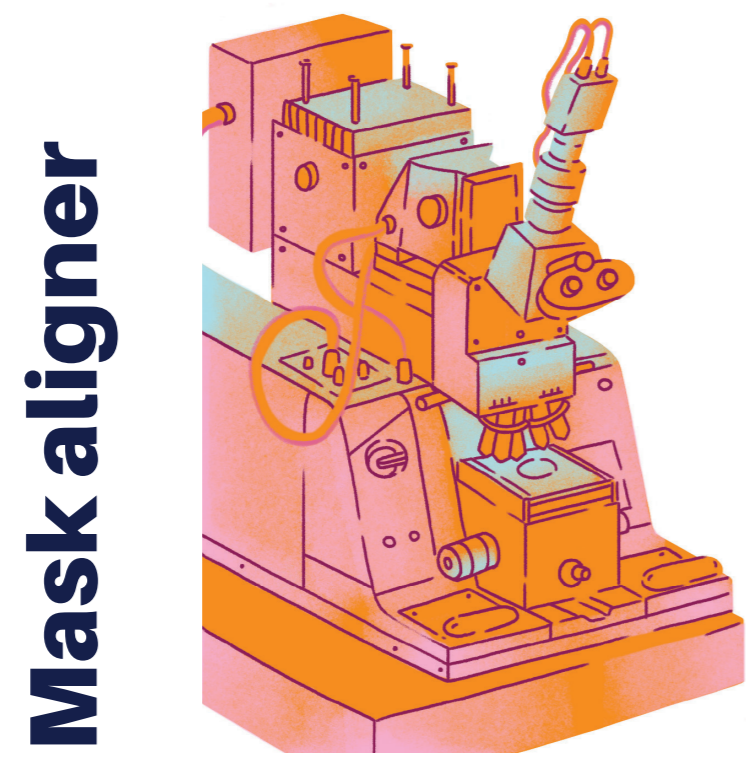
4 Humid zone: the fume cupboard allows to handle liquids. Each cupboard is dedicated to a type of liquid : acid, base, solvent, etc.

6 Grey room: this area is cleaner than the outside but less than the inside of the cleanroom.

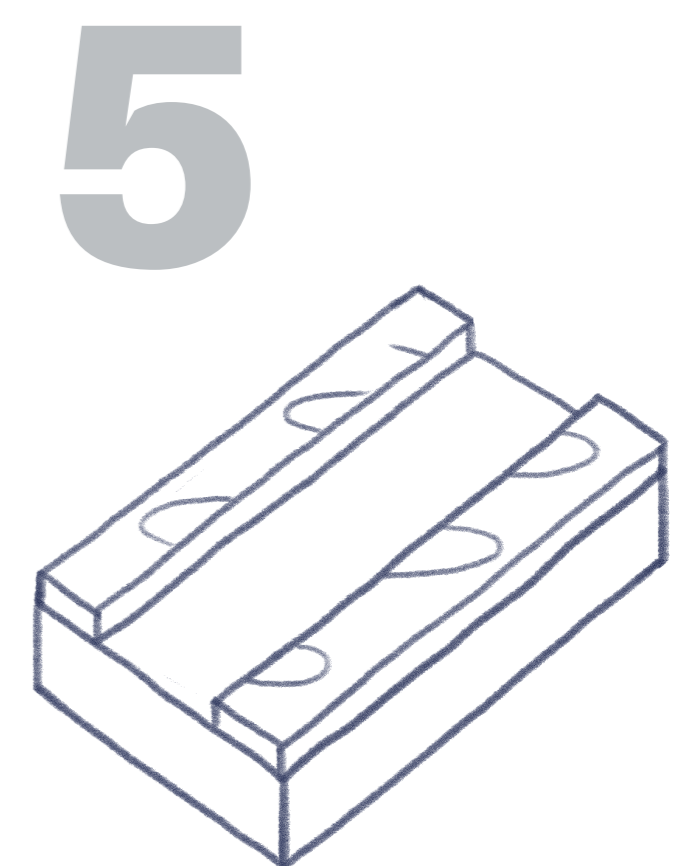
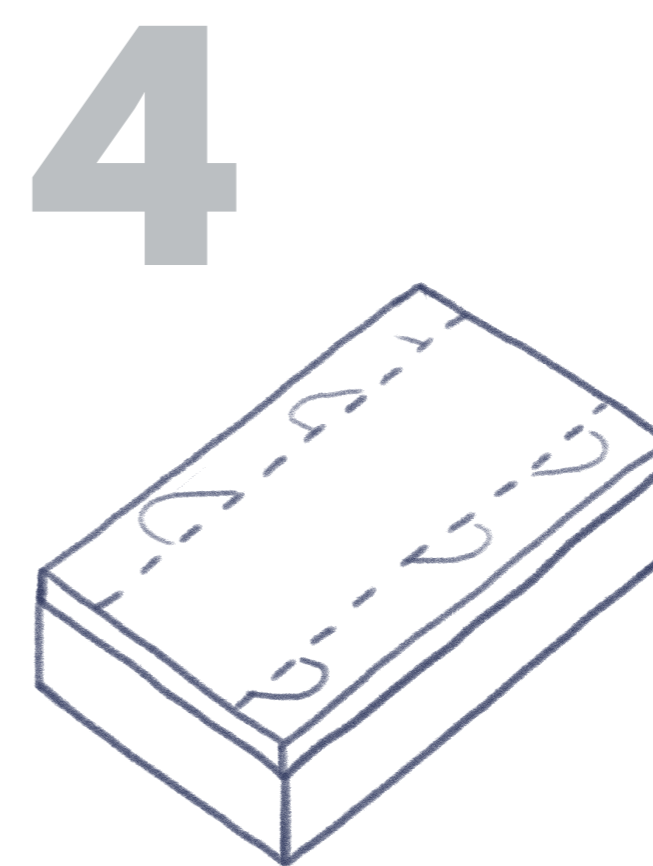
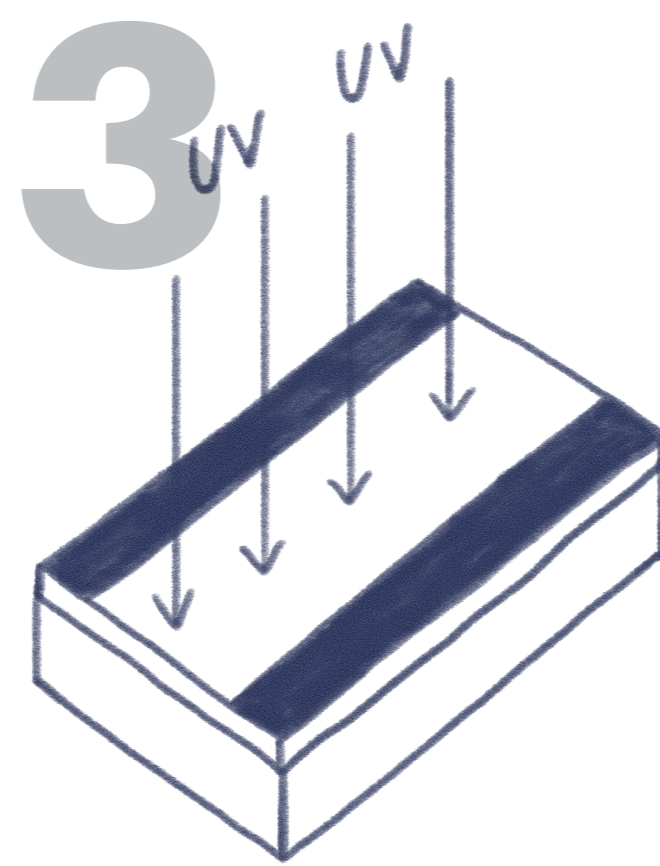
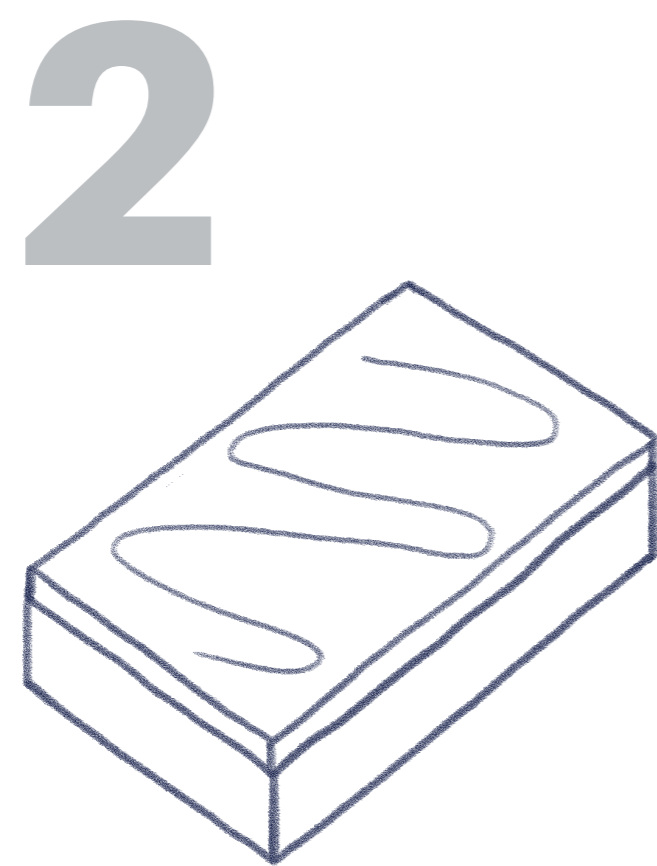
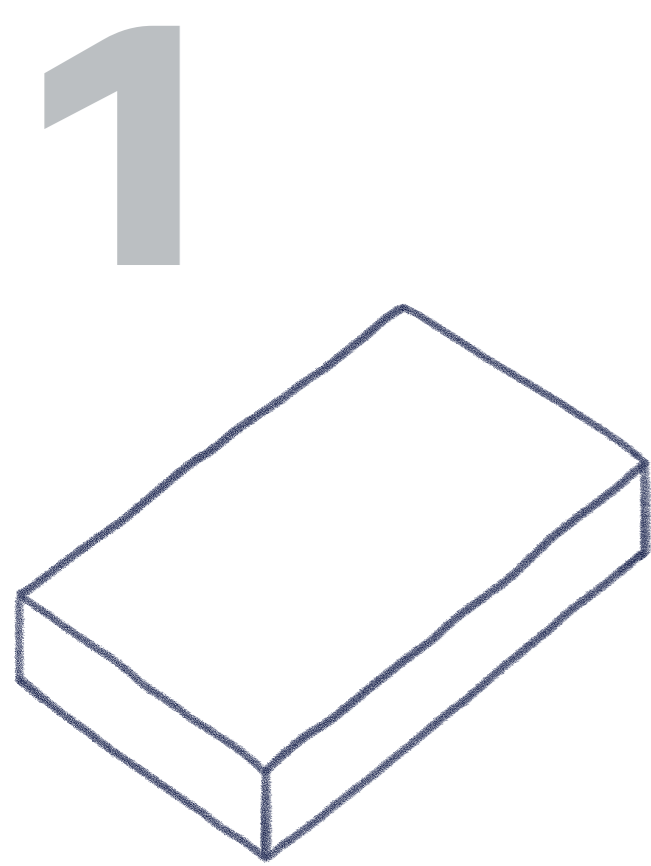
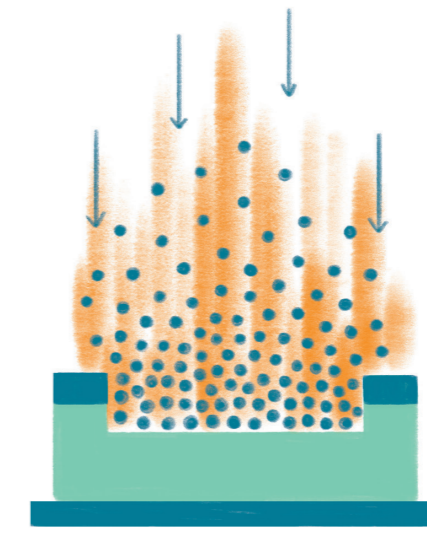
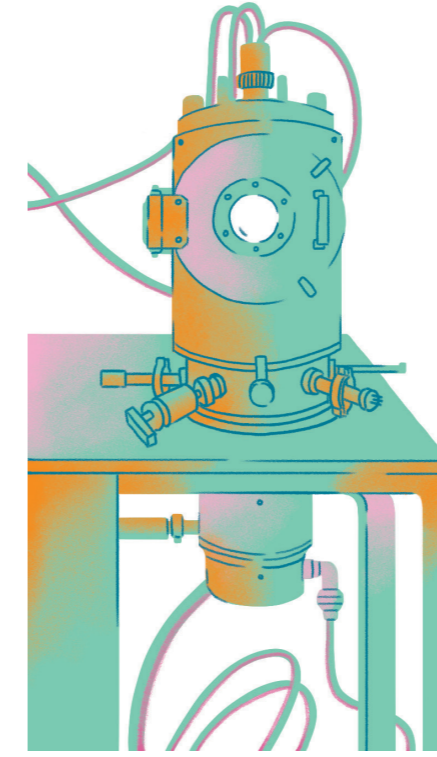
8 Inside the cleanroom, separate room may welcome specific set-up such as Scanning Electron Microscope or Scanning Tunneling Microscope.

Fabrication

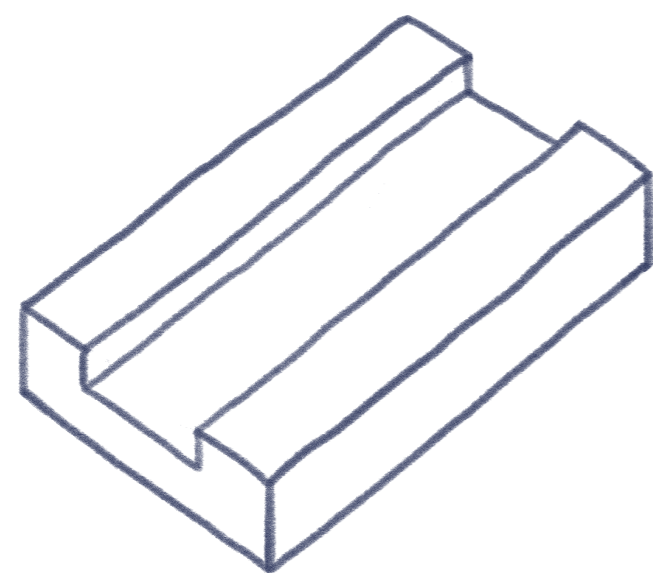
Lithography is a technique used to fabricate at the nano- or micro-meter scale. Many variation of this techniques exist.



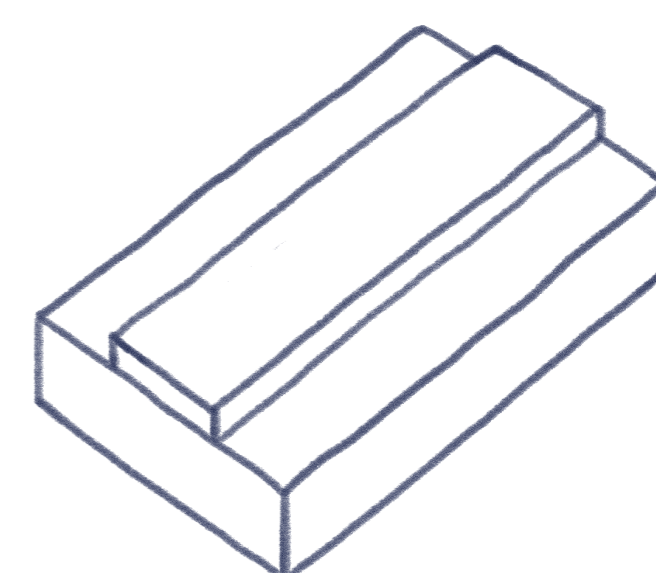
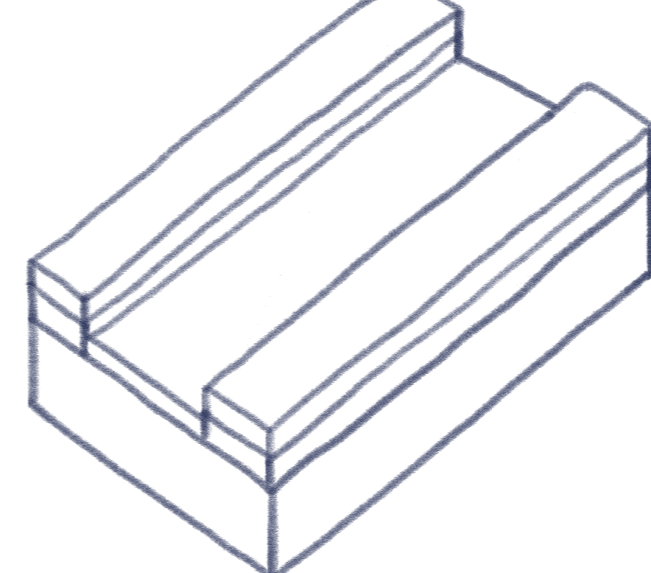
Etching system



6A



6B



1 Clean sample.

2 Resist deposited on the sample.

3 Exposing.

4 The resist is exposed only on the open part of the mask.

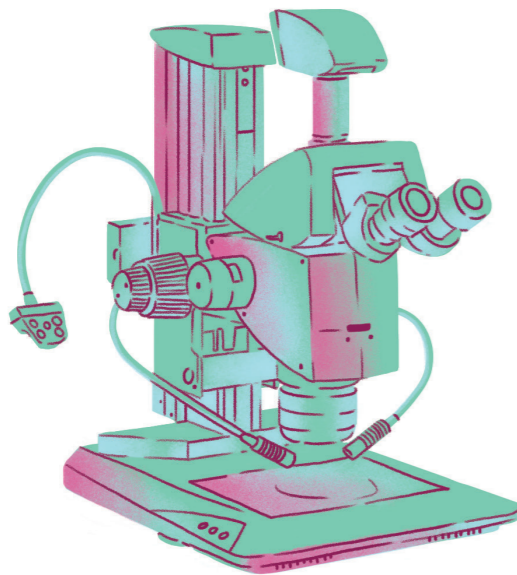
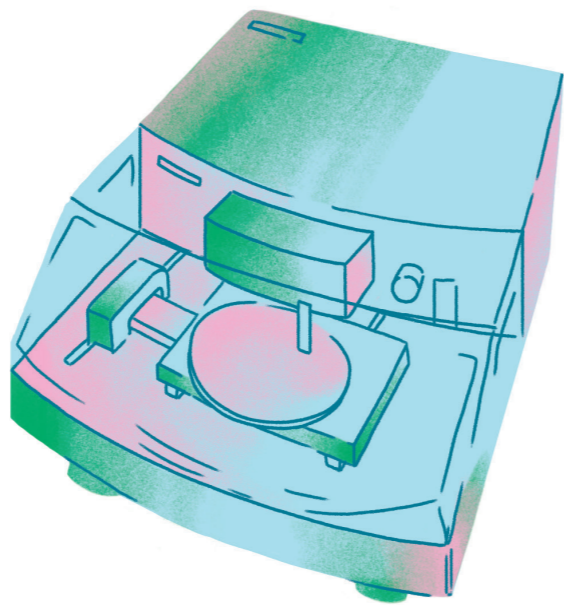
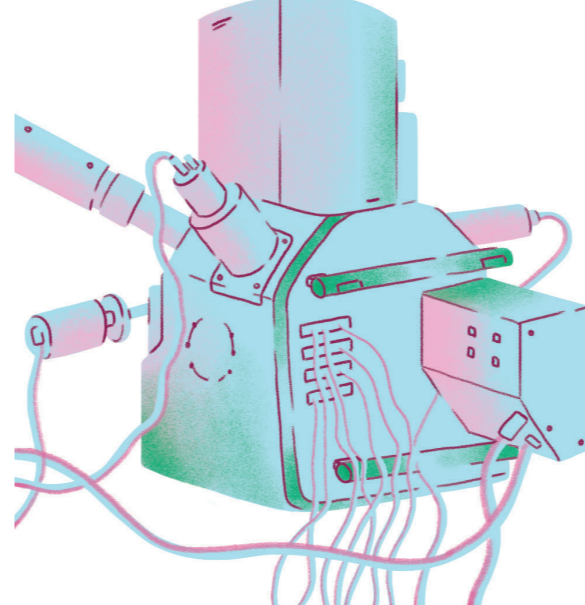
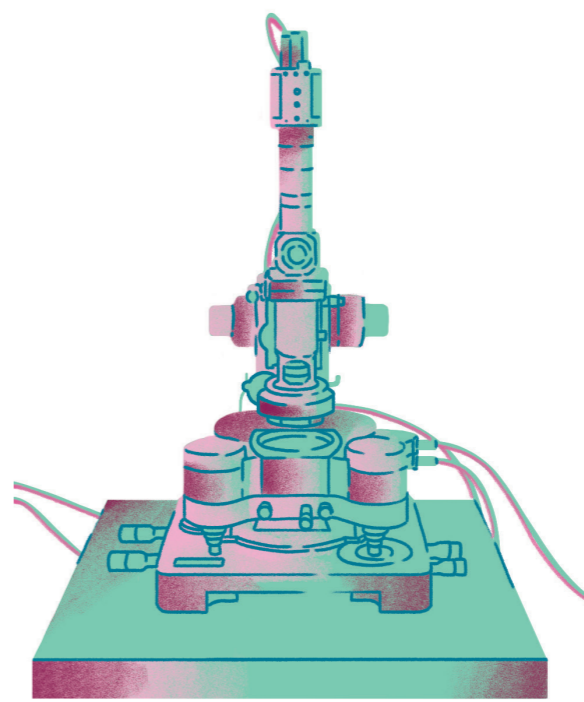
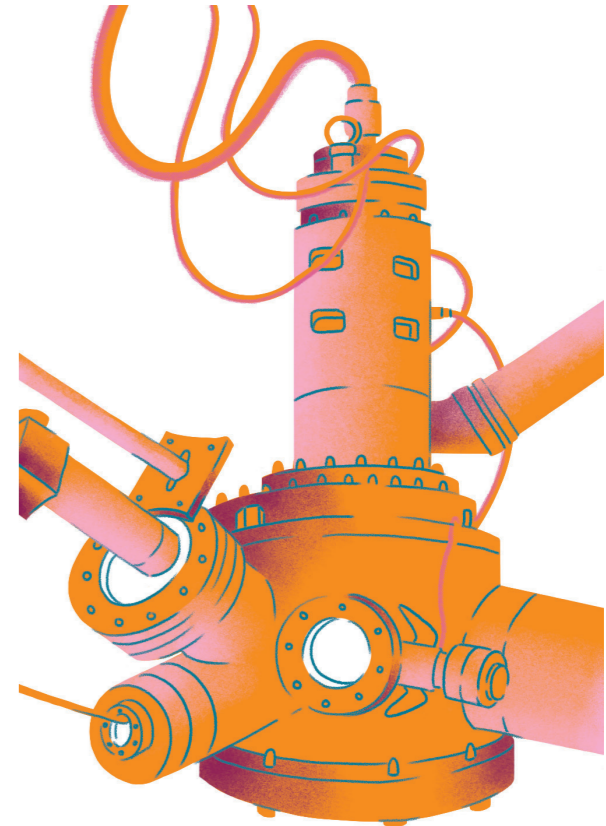
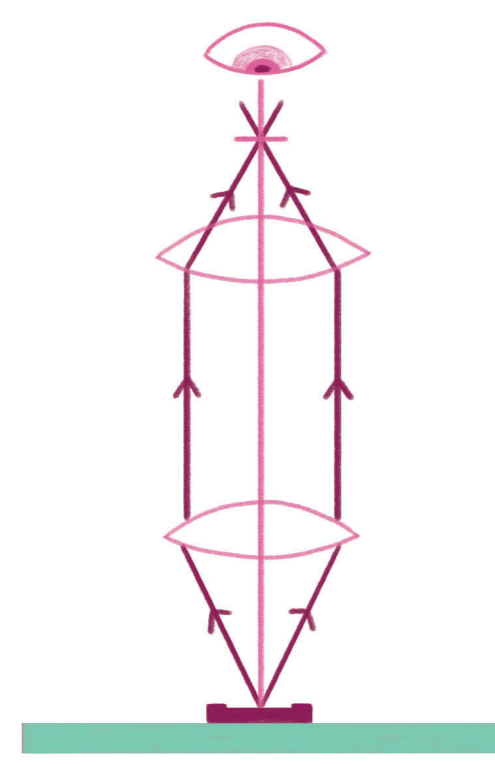
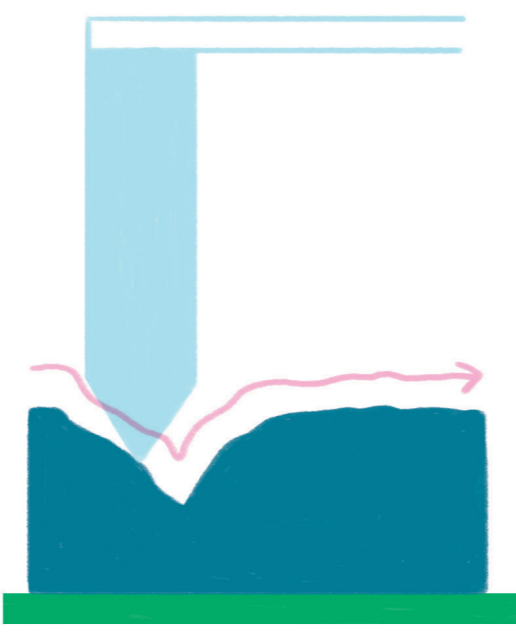
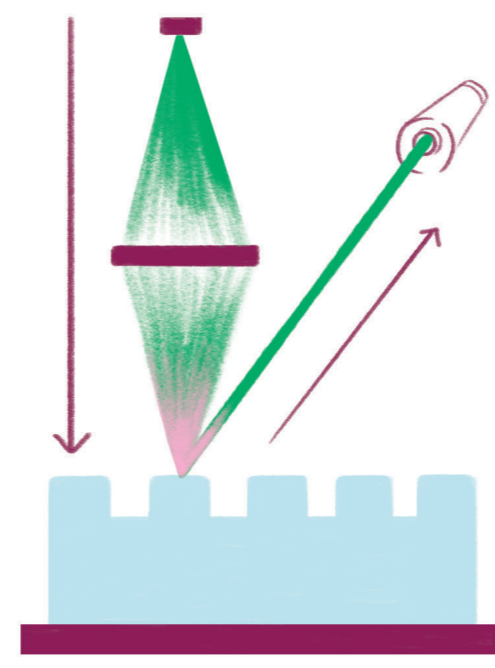
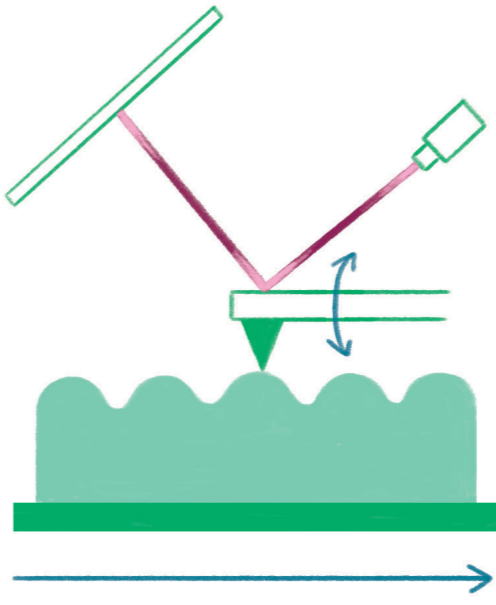
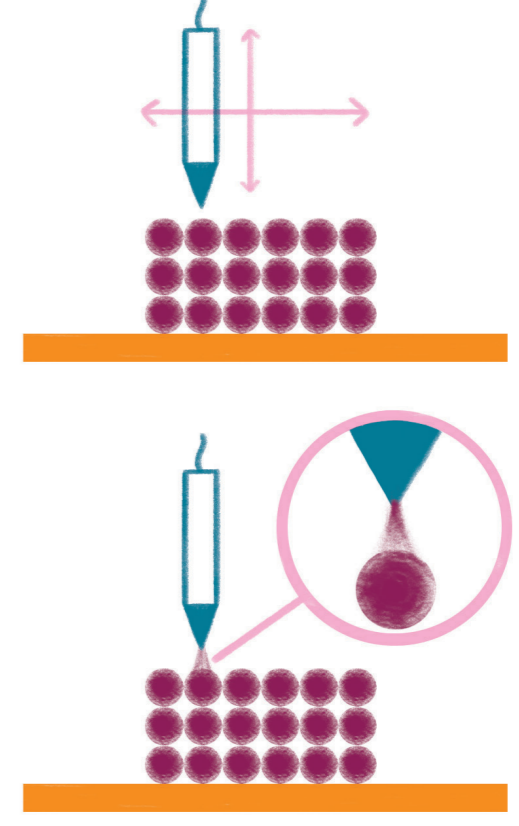
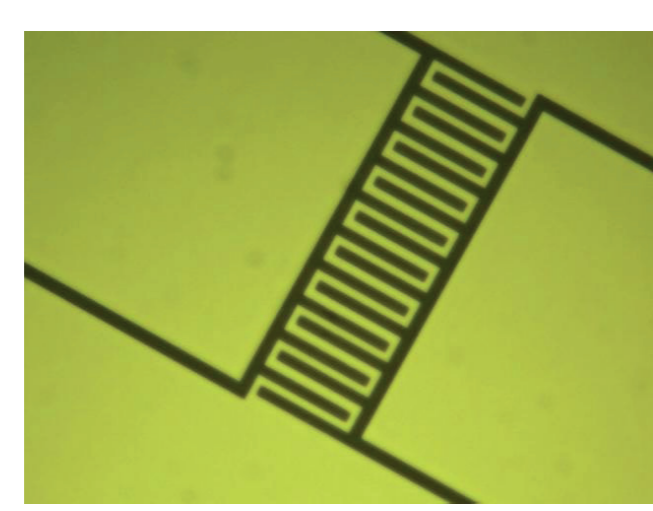
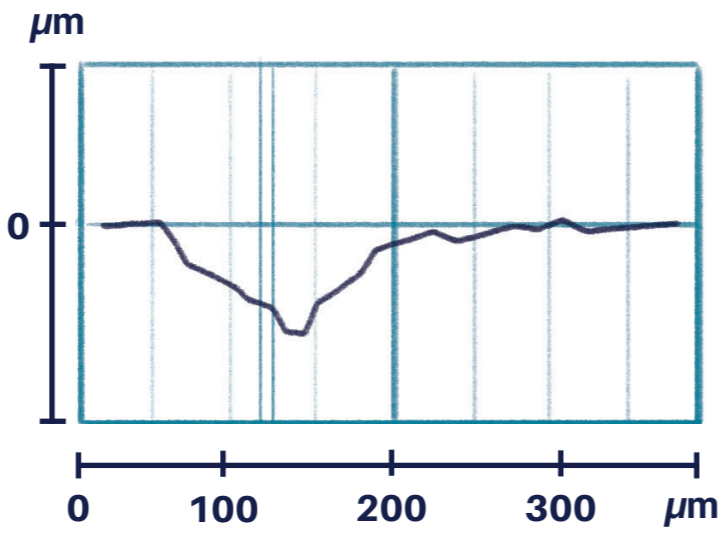
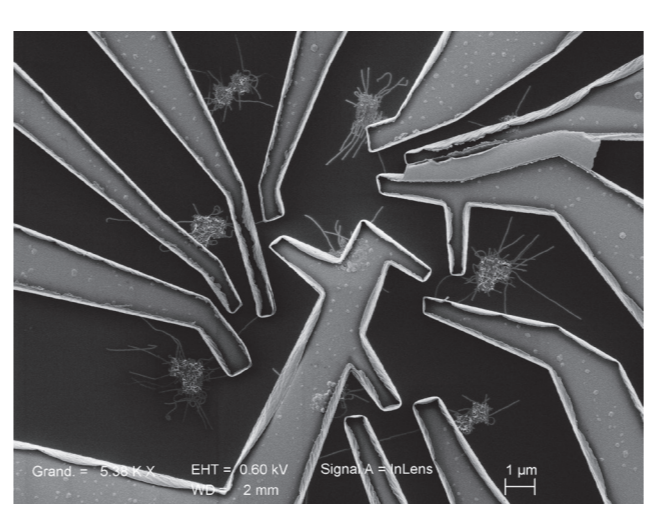

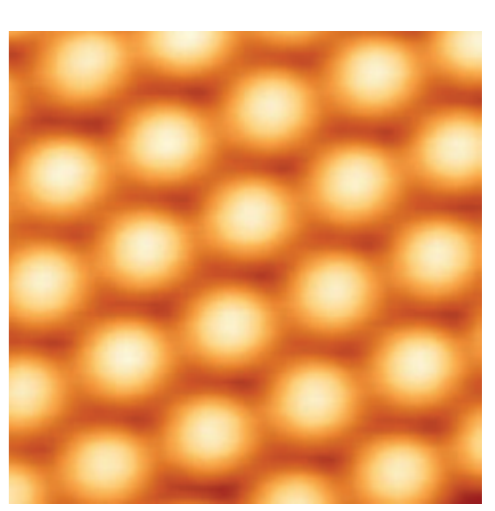
5 Development.

6A Etching.

6B Metal deposition and the lift-off: the resist is dissolved taking away part of the metal.

Characterization

Instrumentations which are used to control the fabrication.

	1	2	3	4	5
	Optical microscope	Profilometer	SEM	AFM	STM
INSTRUMENT					
PRINCIPLE					
IMAGE	 55 μm Interdigitals electrodes.	 Profile for a surface.	 6 μm Quantum dots based on carbon nanotubes.	 2,5 μm DNA plasmids on mica.	 0,6 nm Silicon atoms.

1 The optical microscope exploits the trajectory of light through lenses.

2 The profilometer is used to measure thickness and topography.

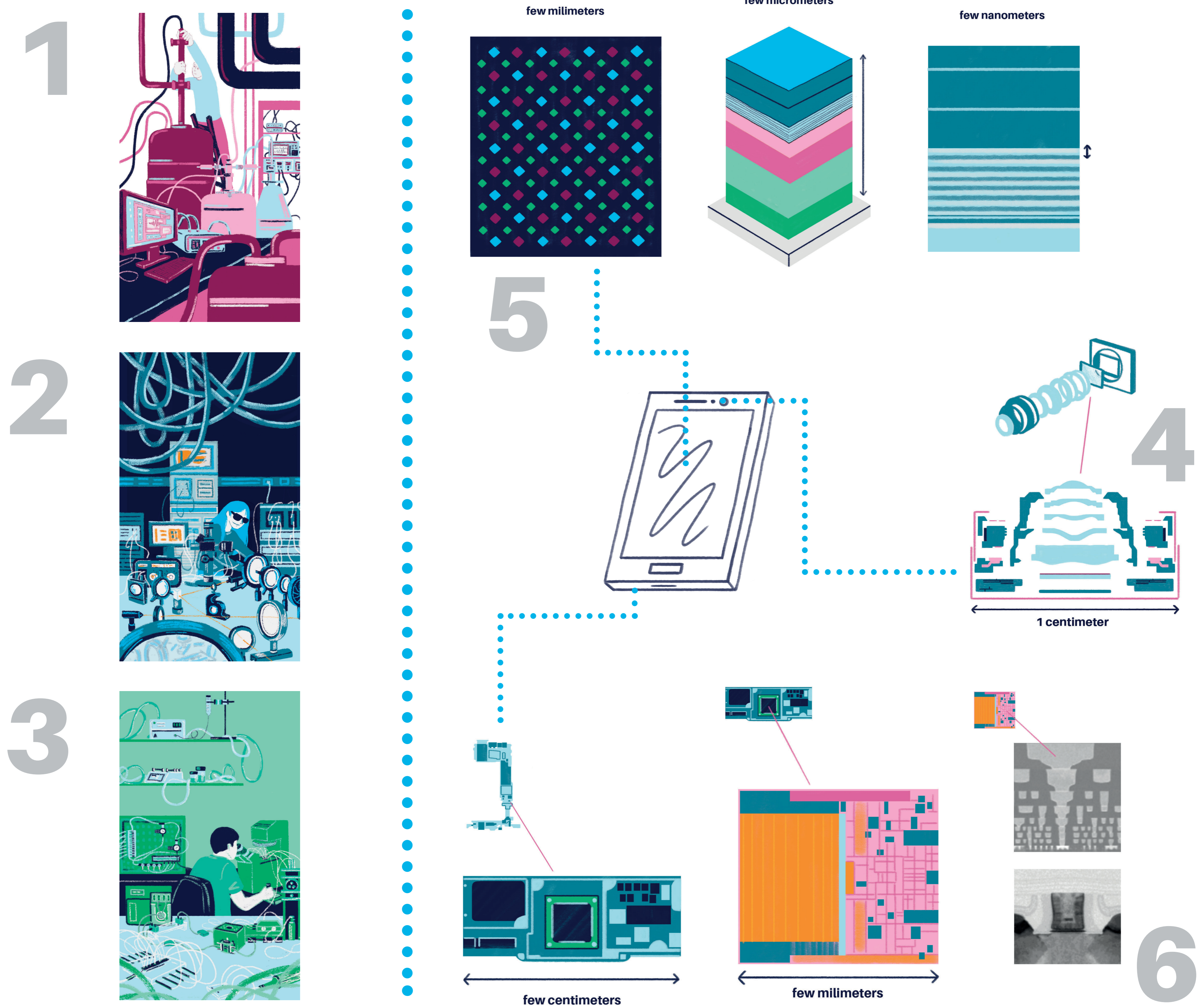
3 SEM: Scanning Electron Microscope. It is used to look at conductive sample up to a few tenth of nanometers.

4 AFM: Atomic Force Microscope. It is used, among others, to measure the roughness of a surface up to 0.1nm.

5 STM: Scanning Tunneling Microscope. Conductive surfaces can be observed with STM at the atomic scale

Researches & Applications

Objects designed in cleanroom are used both for fundamental researches at micro and nano-meter scales and for industrial applications used in our every lives.



1 Solid state physics laboratory: researchers study quantum physics effects at the nanometer scale.

3 Soft Matter laboratory: researchers study the flow of fluids in micro- and nanometer scales canals.

5 The screen is made of 3 colors pixels. Each of them is an electroluminescent diode often made of organic materials. These OLED are composed of stacking of micro and nanometers thick layers.

6 The processor is found among other component in the S.O.C. (System On Chip). Inside the processor, billions of transistors are found as small as a few tenth of nanometers.

2 Photonic laboratory: researchers look at the behavior of photons interacting with nanoobjects.

4 The camera lense is composed of several lenses all made and assembled in clean room.